

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

in re the Application of:

NANJO, Ryota et al.

Serial No.: 10/084,367

Filed: February 28, 2002

Group Art Unit: 2822

Examiner: Toniae M. Thomas

P.T.O. Confirmation No.: 9203

For: SEMICONDUCTOR DEVICE AND ITS MANUFACTURE METHOD

## AMENDMENT AND RESPONSE TO ELECTION OF SPECIES REQUIREMENT

Commissioner for Patents Washington, D.C. 20231

March 3, 2803

Sir:

This is in response to the Office Action of January 31, 2003, requiring an election among various species of the subject invention under the provisions of 35 USC § 121.

## IN THE CLAIMS:

Amend the claims as follows:

1. (Amended) Amethod of manufacturing a semiconductor device according to claim 10, wherein

said step (b) forms first and second gate electrodes in respective partial areas of said first and second regions;

said step (c) implants impurities of the second conductivity type into a surface layer in said second region on both sides of said second gate electrode;